PERMETHYLPOLYAZINE-ETHYLENE PROPYLENE DIENE ELASTOMER (EPDM) AS AN ELECTROACTIVE ACTUATOR



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ABSTRACT

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Elastomers that can respond to external stimuli, such as temperature and electric field, are known as dielectric elastomers, consisting of either a polar molecule or an unsaturated structure on the side chain with induced dipole moments. In our work, we prepared the electroactive polymers from blends of dielectric elastomers and a conductive polymer. For the dielectric elastomers, ethylene propylene diene elastomer (EPDM NORDEL IP 5565) was used as the matrix phase. The conductive polymers, permethylpolyazine (PAZ), were synthesized and doped with iodine at various doping levels for improving the electrical conductivity. The blends were prepared by the mechanical blending of highly doped PAZ particles with EPDM at various particle concentrations from 5 vol% to 20 vol%. The chemical structures of undoped and doped PAZ were characterized by FT-IR. The electromechanical properties were studied under an oscillatory shear mode in the frequency range 0.1-100 rad/s with electric field strength varying from 0 to 1 kV/mm at 27°C. The effects of particle concentration on storage modulus response, $\Delta G'$, storage modulus sensitivity, $\Delta G'/G'_0$, and electrical conductivity, σ , and dielectric constant, ϵ' at 27°C and 100 rad/s were also studied. $\Delta G'$ and $\Delta G'/G'_0$ increase with increasing electric field strength, and particle concentration. The electrical conductivity and dielectric constant increase with particle concentration.

บทคัดย่อ

นางสาวพัชรี อินธนู : การเตรียมวัสคุที่ตอบสนองต่อสนามไฟฟ้าจากเพอร์เมทิลพอลิเอ ซึนและยางเอทีลินพรอพิลีนไดอีนหรือยางอีพีคีเอ็ม (Permethylpolyazine-Ethylene Propylene Diene Elastomer as an Electroactive Actuator) อ. ที่ปรึกษา : รศ. คร. อนุวัฒน์ ศิริวัฒน์ 135 หน้า

ใดอิเล็กทริกอีลาสโตเมอร์ เป็นวัสคุที่มีความสามารถในการตอบสนองต่อสิ่งเร้าภายนอก เช่น อุณหภูมิ และสนามไฟฟ้า ประกอบไปด้วยโมเลกุลที่มีขั้วหรือมีโครงสร้างพันธะไม่อิ่มตัวบน กิ่งของสายโซ่ซึ่งเป็นตัวเหนี่ยวนำให้เกิดไดโพลโมเมนต์ งานวิจัยนี้ได้ทำการเตรียมอิเล็กโตรแอก ทีฟพอลิเมอร์จากไคอิเล็กทริกอีลาสโตเมอร์และพอลิเมอร์นำไฟฟ้า โคยไคอิเล็กทริกอีลาสโตเมอร์ ที่ถูกนำมาใช้ในงานวิจัยนี้คือยางเอทิลีนพรอพิลีนไคอีน หรือยางอีพีดีเอ็มซึ่งทำหน้าที่เป็นเมทริกต์ ในส่วนของพอลิเมอร์นำไฟฟ้าที่ถูกนำมาใช้ในงานวิจัยนี้คือเพอร์เมทิลพอลิเอซีนซึ่งทำหน้าที่เป็น ฟิลเลอร์ และถูกสังเคราะห์ขึ้นรวมไปถึงการปรับปรุงคุณสมบัติทางค้านไฟฟ้าโคยการโคป (doping process) ด้วยสารใอโอดีนในปริมาณที่แตกต่างกัน สำหรับการเตรียมอิเล็กโตรแอคทีฟ พอลิเมอร์ทำใค้โดยการผสมเพอร์เมทิลพอลิเอซีนที่มีปริมาณการโคปสูงสุดลงบนยางอีพีคีเอ็มใน อัตราส่วน 5-20% โดยปริมาตร ซึ่งลักษณะ โครงสร้างทางเคมีของเพอร์เมทิลพอลิเอซีนและเพอร์ เมทิลพอลิเอซีนที่ผ่านการโดปศึกษาได้จากอินฟราเรคสเปกโทรสโกปี นอกจากนี้ยังศึกษาสมบัติ ทางด้านอิเล็กโตรแมคคานิคอล (electromechanical property) ภายใต้แรงออสซิลลารี (oscillatory shear mode) อยู่ในช่วงความถี่ 0.1-100 รอบต่อวินาทีและสนามไฟฟ้า 0-1 กิโล โวลท์ต่อมิลลิเมตร อีกทั้งยังศึกษาถึงผลกระทบของปริมาณเพอร์เมทิลพอลิเอซีนที่มีปริมาณการ โดปสูงสุดบนการตอบสนองของโมดูลัสการสะสม (storage modulus response, $\Delta G'$ and sensitivity, $\Delta G'/G'_0$), ค่าการนำไฟฟ้า (electrical conductivity, σ), และค่าคงที่ใดอิเล็กทริก (dielectric constant, є') ณ อุณหภูมิ 27°C และความถี่ 100 รอบต่อวินาที การตอบสนองของ โมคูลัสการสะสมเพิ่มขึ้นเมื่อขนาคของสนามไฟฟ้าและปริมาณเพอร์เมทิลพอลิเอซีนที่มีปริมาณ การโคปสูงสุดเพิ่มขึ้น ค่าการนำไฟฟ้าเพิ่มขึ้นเมื่อปริมาณเพอร์เมทิลพอลิเอซีนที่มีปริมาณการโคป สูงสุดเพิ่มขึ้นด้วย

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